

L Number	Hits	Search Text	DB	Time stamp
1	1021	438/424.ccls.	USPAT	2004/10/20 17:56
2	212	438/425.ccls.	USPAT	2004/10/20 17:56
3	180	438/426.ccls.	USPAT	2004/10/20 17:56
4	347	438/427.ccls.	USPAT	2004/10/20 17:56
5	275	438/430.ccls.	USPAT	2004/10/20 17:57
6	139	438/431.ccls.	USPAT	2004/10/20 17:57
7	279	438/439.ccls.	USPAT	2004/10/20 17:57
8	132	438/444.ccls.	USPAT	2004/10/20 17:57
9	41	438/446.ccls.	USPAT	2004/10/20 17:57
10	138	438/448.ccls.	USPAT	2004/10/20 17:57
11	723	438/700.ccls.	USPAT	2004/10/20 17:57
12	73	438/295.ccls.	USPAT	2004/10/20 17:58
13	496	438/296.ccls.	USPAT	2004/10/20 17:58
14	424	438/297.ccls.	USPAT	2004/10/20 17:58
15	242	438/294.ccls.	USPAT	2004/10/20 17:58
16	1	takenaka-masahiro\$.in.	USPAT	2004/10/20 18:00
17	3	takenaka-masahiro\$.in.	US-PGPUB	2004/10/20 17:59
18	25	takenaka-masahiro\$.in.	EPO; JPO; DERWENT; IBM_TDB	2004/10/20 17:59
19	12813	((silicon same germanium) "sige") and (trench groov\$6 open\$6 recess\$6)	USPAT	2004/10/20 18:04
20	2061	((silicon same germanium) "sige") and (trench groov\$6 open\$6 recess\$6)) and (strain\$6 relax\$6)	USPAT	2004/10/20 18:03
21	361	((silicon same germanium) "sige") and (trench groov\$6 open\$6 recess\$6)) and (strain\$6 relax\$6)) and (strain\$6 and relax\$6)	USPAT	2004/10/20 18:04
22	754	((silicon same germanium) "sige") and (trench groov\$6 open\$6 recess\$6)) and (strain\$6 relax\$6)) and oxidiz\$9	USPAT	2004/10/20 18:04

23	445	(((silicon same germanium) "sige") and (trench groov\$6 open\$6 recess\$6)) and (strain\$6 relax\$6)) and oxidiz\$9) and (oxidiz\$9 same (silicon polysilicon))	USPAT	2004/10/20 18:04
24	5850	((silicon same germanium) "sige") and (trench groov\$6 open\$6 recess\$6)	US-PGPUB	2004/10/20 18:05
25	468	(((silicon same germanium) "sige") and (trench groov\$6 open\$6 recess\$6)) and (strain\$6 and relax\$6)	US-PGPUB	2004/10/20 18:05
26	305	(((silicon same germanium) "sige") and (trench groov\$6 open\$6 recess\$6)) and (strain\$6 and relax\$6)) and oxidiz\$9	US-PGPUB	2004/10/20 18:05
27	700	((silicon same germanium) "sige") and (trench groov\$6 open\$6 recess\$6)	EPO; JPO; DERWENT; IBM_TDB	2004/10/20 18:06
28	4	(((silicon same germanium) "sige") and (trench groov\$6 open\$6 recess\$6)) and (strain\$6 and relax\$6)	EPO; JPO; DERWENT; IBM_TDB	2004/10/20 18:05
29	39	(((silicon same germanium) "sige") and (trench groov\$6 open\$6 recess\$6)) and oxidiz\$9	EPO; JPO; DERWENT; IBM_TDB	2004/10/20 18:05
30	443	(((silicon same germanium) "sige") and (trench groov\$6 open\$6 recess\$6)) and (((silicon same germanium) "sige") same (trench groov\$6 open\$6 recess\$6))	EPO; JPO; DERWENT; IBM_TDB	2004/10/20 18:06